L Number	Hits	Search Text	DB	Time stamp
3	491	((sulfuric or sulphuric) adj acid) and (water adj drop)	USPAT;	2003/11/15 13:06
		•	US-PGPUB;	
			EPO; JPO; DERWENT;	
			IBM TDB	
6	2	(((sulfuric or sulphuric) adj acid) and (water adj drop)) and ((water	USPAT;	2003/11/15 13:07
"		adj drop) with (storage))	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	4005	40.4400 4.407.444.400	IBM_TDB	000044454000
9	1985	134/100.1,107,111,182.ccls.	USPAT; US-PGPUB;	2003/11/15 13:30
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	•
10	151	134/100.1,107,111,182.ccls. and 134/902.ccls.	USPAT;	2003/11/15 13:29
			US-PGPUB;	
			EPO; JPO;	
			DERWENT; IBM TDB	
11	4	(134/100.1,107,111,182.ccls. and 134/902.ccls.) and (acid with	USPAT;	2003/11/15 13:29
		(regenerat\$3 or recycl\$3))	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
12	13	134/100.1,107,111,182.ccls. and (acid with (regenerat\$3 or	IBM_TDB	2002/44/45 42-20
12	13	recycl\$3))	USPAT; US-PGPUB;	2003/11/15 13:30
		1003014077	EPO; JPO;	
	İ		DERWENT;	
			IBM_TDB	
13	3871	134/100.1,107,111,182,902.ccls.	USPAT;	2003/11/15 13:30
			US-PGPUB; EPO; JPO;	
			DERWENT;	
			IBM TDB	
14	28	134/100.1,107,111,182,902.ccls. and (acid with (regenerat\$3 or	USPAT;	2003/11/15 13:31
		recycl\$3))	US-PGPUB;	
			EPO; JPO; DERWENT;	
			IBM TDB	
-	277	134/\$.ccls. and (sulfuric adj acid) and recycl\$3	USPAT;	2003/11/14 14:16
		• • •	US-PGPUB;	
			EPO; JPO;	,
			DERWENT; IBM_TDB	
-	14	(134/\$.ccls. and (sulfuric adj acid) and recycl\$3) and ((sulfuric adj	USPAT;	2003/11/04 17:07
		acid) with recycl\$3)	US-PGPUB;	===== /
			EPO; JPO;	
ļ			DERWENT;	
_	186	((sulfuric adj acid) with recycl\$3).ti.	IBM_TDB USPAT;	2003/11/04 17:07
	100	τισαπαπό αυμασίας with τσογοίφος	US-PGPUB;	2003/11/04 17:07
			EPO; JPO;	[
			DERWENT;	
	40		IBM_TDB	000044/04 - 5
-	10	(((sulfuric adj acid) with recycl\$3).ti.) and peroxide	USPAT;	2003/11/04 17:08
			US-PGPUB; EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	1348	(sulfuric adj acid) and recycl\$3 and peroxide and (wafer or	USPAT;	2003/11/04 17:10
		semiconductor or substrate)	US-PGPUB;	
			EPO; JPO; DERWENT;	
			IBM_TDB	

-	1160	((sulfuric adj acid) and recycl\$3 and peroxide and (wafer or semiconductor or substrate)) and heat\$3	USPAT; US-PGPUB; EPO; JPO;	2003/11/04 17:14
			DERWENT;	
_	85	(((sulfuric adj acid) and recycl\$3 and peroxide and (wafer or	IBM_TDB USPAT;	2003/11/14 16:21
		semiconductor or substrate)) and heat\$3) and aspirat\$3	US-PGPUB;	2003/11/14 10.21
			EPO; JPO;	
			DERWENT; IBM TDB	
_	5	((((sulfuric adj acid) and recycl\$3 and peroxide and (wafer or	USPAT;	2003/11/04 17:19
		semiconductor or substrate)) and heat\$3) and aspirat\$3) and	US-PGPUB;	
		((purify or purification or recycl\$3 or regenerat\$3) with (sulfuric	EPO; JPO;	
		adj acid))	DERWENT; IBM TDB	
-	279	134/\$.ccls. and ((sulfuric or sulphuric) adj acid) and recycl\$3	USPAT;	2003/11/14 14:16
			US-PGPUB;	
			EPO; JPO; DERWENT;	
			IBM_TDB	
-	124	134/100.0,107,111,182.ccls. and 134/902.ccls.	USPAT;	2003/11/15 13:29
			US-PGPUB; EPO; JPO;	
			DERWENT;	
	3	(124/100 0 107 111 192 colo and 124/002 colo ) and (acid with	IBM_TDB	0000/44/45 40:00
	3	(134/100.0,107,111,182.ccls. and 134/902.ccls.) and (acid with (regenerat\$3 or recycl\$3))	USPAT; US-PGPUB;	2003/11/15 13:30
			EPO; JPO;	
			DERWENT;	
_	925	134/111.ccls.	IBM_TDB USPAT;	2003/11/14 16:23
			US-PGPUB;	2000/11/14 10:20
			EPO; JPO;	
			DERWENT; IBM_TDB	
-	12	134/111.ccls. and ((sulfuric or sulphuric) adj acid)	USPAT;	2003/11/14 16:23
			US-PGPUB; EPO; JPO;	
			DERWENT;	
	1400	/// Mr. 1	IBM_TDB	
-	4469	(((sulfuric or sulphuric) adj acid) with (regenerat\$3 or recycl\$3))	USPAT; US-PGPUB;	2003/11/14 16:25
			EPO; JPO;	
			DERWENT;	
-	430	((((sulfuric or sulphuric) adj acid) with (regenerat\$3 or recycl\$3)))	IBM_TDB USPAT;	2003/11/14 16:25
	.55	and (wafer or semiconductor or substrate)	US-PGPUB;	2005/11/14 10.25
			EPO; JPO;	
			DERWENT; IBM_TDB	
-	329	(((((sulfuric or sulphuric) adj acid) with (regenerat\$3 or recycl\$3)))	USPAT;	2003/11/14 16:26
		and (wafer or semiconductor or substrate)) and heat\$3	US-PGPUB;	
]			EPO; JPO; DERWENT;	
		<u> </u>	IBM_TDB	
-	11	(((((sulfuric or sulphuric) adj acid) with (regenerat\$3 or recycl\$3))) and (wafer or semiconductor or substrate)) and	USPAT;	2003/11/14 16:31
		heat\$3) and 134/\$.ccls.	US-PGPUB; EPO; JPO;	
			DERWENT;	
_	27	"Yasuda, Okimitsu"	IBM_TDB USPAT;	2002/44/44 46:50
	"	radad, Onimidu	US-PGPUB;	2003/11/14 16:53
			EPO; JPO;	
			DERWENT; IBM_TDB	
	L		יטטי ואוטי	

-	77	"Fujii, Seiichi"	USPAT;	2003/11/14 16:53
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	١	"Fulli Caliabi" and (authorize or authorize)	IBM_TDB	2002/44/44 46:54
-	· 4	"Fujii, Seiichi" and (sulfuric or sulphuric)	USPAT; US-PGPUB;	2003/11/14 16:54
			EPO; JPO;	
			DERWENT;	
			IBM TDB	
-	2	"Fujii, Seiichi" and (recycl\$3)	USPAT;	2003/11/14 16:54
			US-PGPUB;	
			EPO; JPO;	
		· ·	DERWENT;	
		<u>.</u>	IBM_TDB	
-	11	1	USPAT;	2003/11/15 13:30
		recycl\$3))	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
_	3	134/\$.ccls. and (((sulfuric or sulphuric) adj acid) with (suction or	IBM_TDB USPAT;	2003/11/14 17:00
1		aspirat\$3))	US-PGPUB;	2000/11/17 17:00
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	360	(((sulfuric or sulphuric) adj acid) with (suction or aspirat\$3))	USPAT;	2003/11/14 17:09
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	24	/ ///culturio or culphurio) adi goid) with (custion or conject@2)\) and	IBM_TDB	2002/44/44 47:07
	24	((((sulfuric or sulphuric) adj acid) with (suction or aspirat\$3))) and ((recycl\$3 or regenerat\$3) with acid)	USPAT; US-PGPUB;	2003/11/14 17:07
1		((100) of Togoticration with acidy	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	78	((((sulfuric or sulphuric) adj acid) with (suction or aspirat\$3))) and	USPAT;	2003/11/14 17:07
		((distill\$5 or recycl\$3 or regenerat\$3) with acid)	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	77	// ///outfusions outphusio) and a sid) with (outstier as assisted (2)))	IBM_TDB	0000/44/44 47.00
-	77	(((((sulfuric or sulphuric) adj acid) with (suction or aspirat\$3))) and ((distill\$5 or recycl\$3 or regenerat\$3) with acid)) and water	USPAT; US-PGPUB;	2003/11/14 17:08
		and ((distings of recyclips of regeneratios) with acid)) and water	EPO; JPO;	
			DERWENT;	
		·	IBM_TDB	
-	17	(((sulfuric or sulphuric) adj acid) with (suction or aspirat\$3) with	USPAT;	2003/11/14 17:15
		distill\$5)	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	0575	(the distance of the color of t	IBM_TDB	00004444
-	2575	(((sulfuric or sulphuric) adj acid) with (water) with distill\$5)	USPAT;	2003/11/14 17:25
			US-PGPUB;	·
			EPO; JPO; DERWENT;	[
			IBM_TDB	
-	1125	( (((sulfuric or sulphuric) adj acid) with (water) with distill\$5)) and	USPAT;	2003/11/14 17:12
		(suction or vacuum)	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	76	(((sulfuric or sulphuric) adj acid) with (water) with distill\$5 with	USPAT;	2003/11/14 17:12
		(aspirat\$3 or vacuum or suc\$4))	US-PGPUB;	
			EPO; JPO; DERWENT;	
]			IBM_TDB	
h		<u></u>		

		·		
	3149	((sulfuric or sulphuric) adj acid) near3 (distill\$5 or recycl\$3 or regenerat\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/11/14 17:16
-	17	((sulfuric or sulphuric) adj acid) near3 (distill\$5 or recycl\$3 or regenerat\$3) with (water) with (aspirat\$3 or vacuum or suction)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/11/14 17:20
<b>.</b>	21	((sulfuric or sulphuric) adj acid) near4 (distill\$5 or recycl\$3 or regenerat\$3) with (water) with (aspirat\$3 or vacuum or suction)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/11/14 17:21
-	9	((sulfuric or sulphuric) adj acid) with (distill\$5 or recycl\$3 or regenerat\$3) with (water) with (aspirat\$3 or vacuum or suction) with heat\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/14 17:21
-	162	(((sulfuric or sulphuric) adj acid) near (distill\$5 or recycl\$3 or regenerat\$3)).ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/14 17:25
_	4	((((sulfuric or sulphuric) adj acid) near (distill\$5 or recycl\$3 or regenerat\$3)).ti.) and (vacuum or aspirat\$3 or suc\$4)	USPAT	2003/11/14 17:26